			OB	Time stamp
Number	Hits		JSPAT	2003/03/24 12:59
- Tunnetz	0	Search Text (chung-chia-chi hsueh-chen-chen-calvin).in. and damascene (chung-chia-chi hsueh-chen-chen-calvin).in. and damascene	JSPAT	2003/03/20 12:32
				1
	ł	"carbon-fluoride" (fluori\$2 adj1 carbon)) with (resist photoresist		
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		adj1 carbon adj1 fluori\$2 (fluori\$2 adj1 carbon) with (resist photoresist mask opening layer) adj1 fluori\$2 adj1 carbon)) with (resist photoresist mask opening		
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	7	11 december 11 (lover film)) ((IIIII lavel) auli caroni auj.	USPAT	2003/03/20
	' }			
	İ	fluori\$2) (fluori\$2 adj1 carbon adj1 (layer flim)) (fluori\$2 adj1 carbon)) with (resist photoresist mask opening via trench		
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		groove)).bi. ((dual double) adj1 damascene) and ((carbon adj1 fluori\$2)	USPAT	2003/03/20 12.30
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		carbon)) with (resist photoresist mask opening the carbon adj1 ((((carbon adj1 fluori\$2 adj1 (layer film)) ((film layer) adj1 carbon adj1		
	1	(((((carbon adjl fluori\$2 adjl (layer film)) ((film layer) adjl		
	1	((((carbon adj1 fluori\$2 adj1 (layer film)) ((film layer) adj1 fluori\$2) (fluori\$2 adj1 carbon adj1 (layer film)) ((film layer) adj1		
		fluori\$2) (fluori\$2 adj1 carbon adj1 (layer film)) ((tabel) fluori\$2 adj1 carbon)) with (resist photoresist mask opening via trench		
	1	groove)).bi.))	USPAT	2003/03/20 12:31
	718	groove)).bi.)) ((dual double) adj1 damascene) and ((carbon adj1 fluori\$2) polymer		
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-	187	1 1 1 1 1 1 1 1 1 1 1 1 1 1 1 1 1 1 1	0022	
		((dual double) adj1 damascene) and ((cureon day) polimide (fluori\$2 adj1 carbon)) with (resist photoresist mask opening		
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-	161	and ((carbon add) (1001152) polyinor	OBITI	
	101			
		the standard by the land (((d)) and ((d)) and ((d))	}	
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-	301	"I'd with a E out y" polymer notimide (Illustiaz auji caroni)) "Tar (
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	1		USPAT	2003/03/24 10.5
-	13		1	
		"C.sub.x F.sub.y" polymer politimae (fluoriaz au) rearrow, photoresist mask opening via trench groove)).bi.) and (ratio with carbon photoresist mask opening via trench groove)).		
	l	1		2003/03/24 11:0
		with fluorine) ((dual double) adj1 damascene) and ((carbon adj1 fluori\$2) polymer ((dual double) adj1 damascene) with (regist photoresist mask opening	USPAT	2003/03/24 11.0
-	18	7 ((dual double) adj1 damascene) and ((carbon day) polimide (fluori\$2 adj1 carbon)) with (resist photoresist mask opening		
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	1	via trench groove).bi. 4 (damascene and (((carbon adj1 fluori\$2) "CF" "C:F" "C.sub.5 F.sub.8"	USPAT	2003/03/24 11:0
-	11			
	1			}
	1	adjl damascene) and ((carbon adjl internet) partial adjl carbon)) with (resist photoresist mask opening via trench	- [
	- (groove).bi.)		